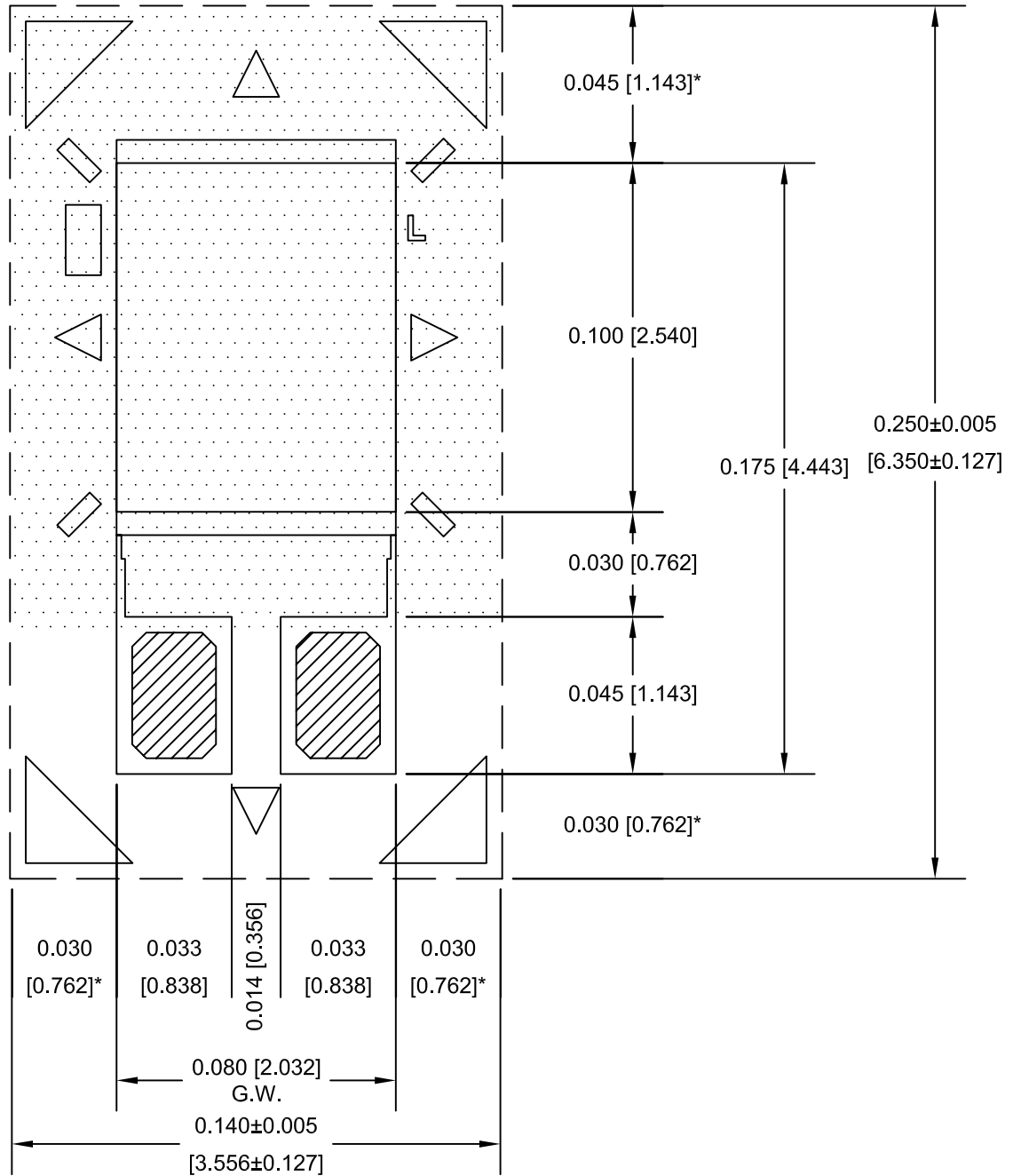


LTR	REVISION	ERN	INITIAL	DATE
~			AR	2012-10-25



* THESE MATRIX RELATED DIMENSIONS ARE ±.0025 [±0.06]

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Micro-Measurements
Raleigh, North Carolina USA



S5029 PATTERN LAYOUT

CONSTRUCTION:

N2K

OPTIONS:

E3, DG

RESISTANCE:

4500±0.2%

REFERENCE:

DRAWN BY:

AR

PROJ. ENG.

GY

DATE:

2012-10-25

DATE:

2012-10-25

SCALE:

N.T.S.

DWG. #

MS-S5029-10010

ALL DIMENSIONS ARE IN INCHES UNLESS OTHERWISE SPECIFIED.

REVISION:

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